

06/18/01

ISSUE CLASSIFICATION	
Class	Subclass

PATENT NUMBER

U.S. UTILITY Patent Application

SA SCANNED <i>Edz</i> Q.A. <i>Am</i>	O.I.P.E.	PATENT DATE
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APPLICATION NO. 09/883437	CONT/PRIOR	CLASS 438	SUBCLASS 1T	ART UNIT 2813	EXAMINER HUYNH
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APPLICANTS

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Tobias Mono

TIME

High contrast lithography alignment marks for semiconductor manufacturing

PTO-2040
12/99

ISSUING CLASSIFICATION									
ORIGINAL				CROSS REFERENCE(S)					
CLASS		SUBCLASS		CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)				
INTERNATIONAL CLASSIFICATION									

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<input type="checkbox"/> TERMINAL DISCLAIMER	DRAWINGS			CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
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<input type="checkbox"/> The term of this patent shall not extend beyond the expiration date of U.S Patent. No. _____ _____ _____	_____ (Primary Examiner) (Date)			ISSUE FEE	
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<input type="checkbox"/> The terminal ____months of this patent have been disclaimed.	_____ (Lead Instruments Examiner) (Date)			ISSUE BATCH NUMBER	

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